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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Sadayoshi HORII et al.

ATTN: Application Branch

Application No.: 10/529,466

Docket No.: 123373

Filed: May 2, 2005

For: MANUFACTURING METHOD OF SEMICONDUCTOR DEVICE AND
SUBSTRATE PROCESSING APPARATUS

CORRECTED FILING RECEIPT STATUS REQUEST (SECOND REQUEST)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

The above-identified application satisfied the requirements of 35 U.S.C. §371 on May 2, 2005, and was accorded U.S. Application No. 10/529,466. Applicants filed a Request for Correction of PALM Records on October 17, 2005 to reflect the May 2, 2005 §371(c) date and to correct the title (copy enclosed). However, Applicants to date have not received a Corrected Official Filing Receipt.

Applicants hereby request that a Corrected Official Filing Receipt be promptly forwarded to Applicants' representative.

Respectfully submitted,

James A. Oliff
Registration No. 27,075

Kristin K. Vidovich
Registration No. 41,448

JAO:KKV/kam

Date: November 15, 2006

OLIFF & BERRIDGE, PLC
P.O. Box 19928
Alexandria, Virginia 22320
Telephone: (703) 836-6400

PTO RECEIPT FOR FILING OF PAPERS

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The following papers have been filed:

Request for Correction of PALM Records; Marked-up OFR; Prelim

Name of Applicant: Sadayoshi HORII et al.

Serial No.: 10/529,466

Atty. File No.: 123373

Title (New Cases):

Sender's Initials: JAO/yxm

PATENT OFFICE DATE STAMP



40/13

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277 S. Washington Street, Suite 500, Alexandria, Virginia 22314

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Attn: OIPE

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For: MANUFACTURING METHOD OF SEMICONDUCTOR DEVICE AND
SUBSTRATE PROCESSING APPARATUS

REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

James A. Oliff
Registration No. 27,075

Jesse O. Collier
Registration No. 53,839

JAO:JOC/yxm

Date: October 17, 2005

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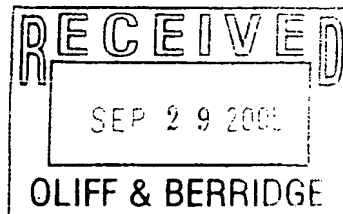


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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/529,466	03/29/2005 5/2/2005	2812	900	123373	11	11	2

25944
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 P.O. BOX 19928
 ALEXANDRIA, VA 22320



CONFIRMATION NO. 8082

FILING RECEIPT



OC000000017086170

Date Mailed: 09/28/2005

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Sadayoshi Horii, Tokyo, JAPAN;
 Hironobu Miya, Tokyo, JAPAN;

Assignment For Published Patent Application

Hitachi Kokusai Electronic, Inc., Nakano-ku, Tokyo, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number **25944**.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/13606 10/24/2003

Foreign Applications

JAPAN 2002-316154 10/30/2002

Projected Publication Date: 12/29/2005

Non-Publication Request: No

Early Publication Request: No

Title

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for manufacturing semiconductor device and substrate processing system

MANUFACTURING METHOD OF SEMICONDUCTOR DEVICE AND SUBSTRATE PROCESSING APPARATUS

Preliminary Class 438

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